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, .pp. 0 10 a 01===.	R & D CATALO		DATE	ch 1965	25
vacuum Easel De		short project description Development of a vacu Enlarger.			25
5. class of contractor Manufacturer		CPFF			25
7. FUNDS	8.	REQUISITION NO.			
FY 19 \$		NA			
FY 1965		effective CONTRACT DATE (Begin - end) 25	5X1		
FY 19 \$		rch 1965 - June 1965			
12. RESPONSIBLE DIRECTORATE	OFFICE/PROJECT	OFFICER TELEPHONE EXTENSION			25
DDI/NPIC/P&DS					25)
inherent edge-curl particular weights, masks, etc.	roblems, on t	ment will permit the The Enlarge the paper. The requi	r without the r	necessity	for
14. TYPE OF WORK TO BE DONE					2/
Engineering Develop	pment				2
				····	
15. CATEGORIES OF EFFORT MAJOR CATEGOR	Y		SUB - CATEGOR   ES#		
Reproduction and Pro- equipment (Equipmen- cation)		Interpretat <b>i</b> on/	Anal <b>y</b> sis		
16. END ITEM OR SERVICES FR	OM THIS CONTRACT	/IMPROVEMENT OVER CURRENT S	YSTEM, EQUIPMENT, E	TC.	
The contract will rement. The improved opaper on any area of flat.  17. SUPPORTING OR RELATED C	easel will er the vacuum e	able the operator to easel and the paper w	place photogra	phic prin	tins
From contacts through			e community, it	: has heen	
determined that no of	ther developm	ent of this type is p	presently under	way.	25
Review by NIMA / DoD					
and hold printing par very time-consuming a The development of the NPIC proposes to the principles descri- Invention" by	) The present per during the and ineffecture ne vacuum eas o investigate lbed in an at	easel requires the exposure cycle. The the particularly when the will the design and fabrication	the use of weine consequent part over-sized part eliminate this te a vacuum east tled "Brief Des	ghts to fine procedure apper is ut apper is ut appear to be appled to	lattis is iliz 25 ing of
19. APPROVED BY AND DATE	-	T miles		orea oo	( 0011
OFFICE	DEPUTY DIRECTOR	0 17: CIA-RDP78B04747A	.002700040004-5		25
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## R & D CATALOG FORM (continued)

- 13. levied by NPIC/PPS.
- 18. full potential. Although a crude and workable easel could easily be built from the invention description as it now stands, it is more important to detail the application by establishing the best method of implementation. The best method will only result from a thorough analysis of the pneumatic principles involved and should result in a unique and vastly superior vacuum easel.

Specific objectives to be accomplished under this development are as follows: the vacuum easel shall

- A. hold flat all conventional weights of printing paper.
- B. permit easy positioning of the printing paper on the format.
- C. provide rapid vacuum "take down".
- D. permit rapid vacuum release.
- E. permit rapid hold-down without creating "dimples" or other blemishes on the paper.
- F. place material in the same focal plane as the present easel's.
- G. hold down all sizes of printing paper without regard to position on the easel format and without the use of masks etc.

A Development Objective was written for this project and proposals were solicited from local companies. Only local companies were						
invited because it was necessary to brief each company on the new						
techniques after having them sign patent disclosure papers						
<u> </u>						
After considerable weighing of technical						
and monetary considerations, it was decided that we are obliged to select						
the proposal for the following reasons:						
7 m						
1. This easel incorporates a new and unique vacuum hold-down						
technique which promises a break-through in vacuum platen technology;						
however, it has never been implemented before and the techniques of						
fabrication and the exact pneumatic principles involved are not known in						
detail. A comprehensive theoretical investigation of these problem						
areas by competent engineers will be required prior to an attempt to						
implement this system: has the necessary engineering staff,						

25X1

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R & D CATALOG FORM (continued) 18. 25X1 2. proposal indicates a fundamental understanding of the prob<u>lem areas</u> 25X1 25X1 proposal elucidates some superior design and fabrication features: e.g., they plan to use a special casting to provide internal support to the vacuum surface thereby increasing rigidity and assuring optical flatness of the printing surface. To the contrary, proposes to use sheet metal construction: optical considerations 25X1 should obviate this approach. 25X1 attempted to produce a vacuum easel for this same enlarger and was totally unsuccessful, resulting in a loss to the agency 25X1 They were invited to propose again only because it was feared that few local companies would be interested in a contract for such a small modification and that we might have to consider them as a last resort. 5. It is our opinion 25X1 has vastly underbid, the contract and is incapable of producing the device we want. 25X1 has far superior engineering capabilities, a highly competent technical staff, and offers the best technical approach in their proposal, they were selected as the potential contractor. Although the proper security measures are not in effect at the contractor's plant, the necessary company officers have Agency secret

## BRIEF DESCRIPTION OF INVENTION

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This invention consists of a system of manifolds and valves coupled to a porous platen in such a way that a vacuum applied to a manifold on one side of the valves will be automatically masked or cut-off by these valves except in those areas where a relatively non-porous material has been placed on the opposite side of the platen. In that case, the covered valves automatically open and allow the vacuum to be applied to the substance placed on the platen. By this means a vacuum platen of relatively large area can be automatically masked so that it will effectively exert the system's full capacity on flat materials placed on the platen even though a relatively small portion of the platen is covered by the material.

This automatic masking is accomplished in the following manner:

- (1) The platen is honey-combed with individual identical cells.
- (2) In the accompanying drawing these cells are joined at the bottom to a manifold (A), to which a vacuum pump is attached.
- (3) Each cell consists of an automatic control or governor value (in the drawing illustrated by a flat spring or reed valve, (B) pierced by a small by-pass port, b, and leading into individual small manifolds, (C).
- (4) Those manifolds are covered by a flat porous platen, (D). (Closely spaced, small holes would also be satisfactory.) The porosity of the platen is such that it will support relatively flimsy material without deformation. Yet, when uncovered, it will allow adequate flow of air causing the control valve to close, and thus reducing the flow to that allowed by the by-pass port.
- (5) In the instance that a relatively non-porous substance, (E), is placed on the platen, the flow of air is restricted and the leakage of the by-pass port allows the pressure in the upper and lower manifolds to equalize.

This will, in turn, cause the control valve to open, thereby allowing a greatly increased flow to pull and hold the substance down on the platen.

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This automatically masked vacuum platen should have extensive application in a number of situations whenever it is necessary to hold flat-sided objects in place with forces not exceeding that of atmospheric pressure. Also, the objects may vary in size and shape with respect to the platen on which they are held in place. Some examples of these applications are:

- (1) Photographic cameras, enlargers, copy boards, printers, etc.
- (2) Coordinatographs, automatic point and line plotters, stereo plotters, drafting boards.
- (3) Model shops for holding work on shaping tables, drill presses, etc.
- (4) Optical shops for handling glass prisms and plates, etc.

	This invention was conceived in the course of official duties. An	
	assignment had been given to define objectives for the	- '
	development of a vacuum easel needed for photo-enlargers	25X1
	to initiate and monitor this development through a contract with industry.	23/1
	In the course of this development	25X1
ı	of holding down miscellaneous sizes of	
	double-weight print paper. In the course of this discussion the idea	
	for the Automatically-Masked Vacuum Platen was conceived. Subsequent	
	component research and discussion refined the idea into the invention	
	described herein.	
	responsible for initiating and	
	monitoring development contracts with private industry. Whereas they	7
	are expected to contribute to such development, evaluation of a complete	
	specific invention such as this is not among their assigned responsi-	
	bilities.	

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AUTOMATICALLY-MASKED VACUUM PLATEN FOR RECORD OF INVENTION OATED 14 DECEMBER 1961

